

Supporting Information

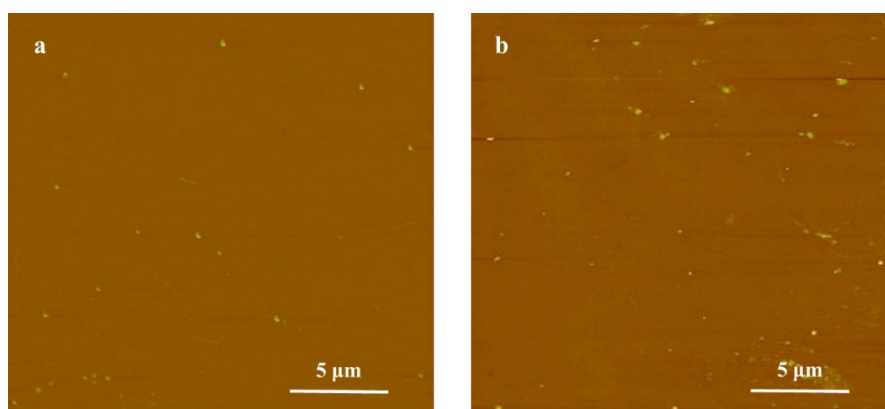


Figure S1. AFM images of the Si wafer removed from the (a) high M_w and (b) low M_w P3HT solutions ultrasonicated for 10 min and crystallized at 20 °C for 24 h.

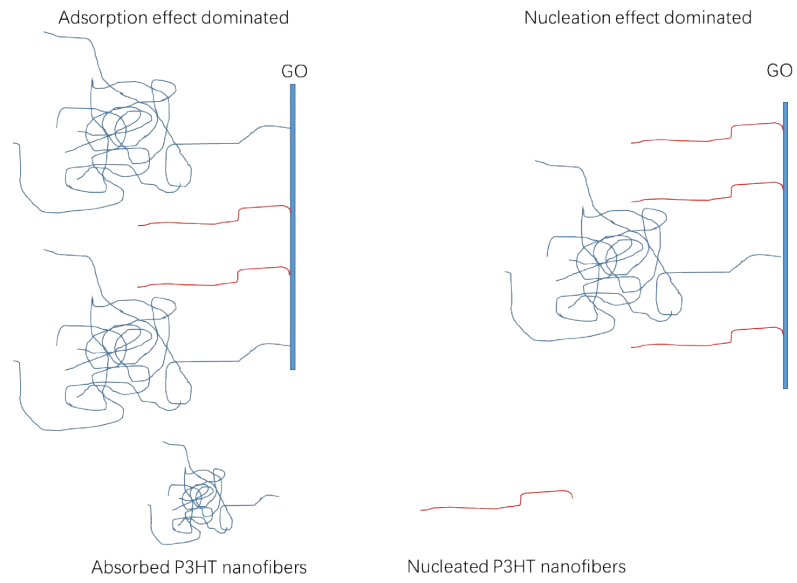


Figure S2. The schematic of the absorbed P3HT nanofibers and nucleated P3HT nanofibers on GO surface.